Supporting Information

Pressure sensitive adhesive with controllable adhesion for fabrication of ultrathin soft devices

Yun Hee Ju,¹ Hee-Jin Lee,² Chul Jong Han,² Cheul-Ro Lee,¹ Youngmin Kim,^{2,*} and Jong-Woong Kim^{1,*}

¹School of Advanced Materials Engineering, Jeonbuk National University, 567 Baekje-daero, Deokjin-gu, Jeonju 54896, Republic of Korea

²Display Research Center, Korea Electronics Technology Institute, 25 Saenariro, Bundang-gu, Seongnam 13509, Republic of Korea

Corresponding Author

*J.-W. K.: Tel: +82 63 270 2292, E-mail address: wyjd@jbnu.ac.kr

*Y. K.: Tel: +82 31 789 7432, E-mail address: ymkim@keti.re.kr

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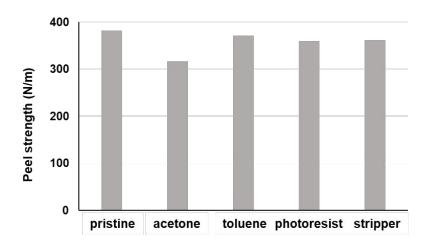


Figure S1. The peel strength of PSA-1 tape before and after solvent treatment. As the developing and stripping processes for photolithography need less than 1 min, the PSA-1 tape adhered to a SUS plate was immersed in the various solvents for 1 min and subject to 180° peel test. The little change in peel strength after solvent treatment means that PSA-1 tape is compatible with the photolithography process.

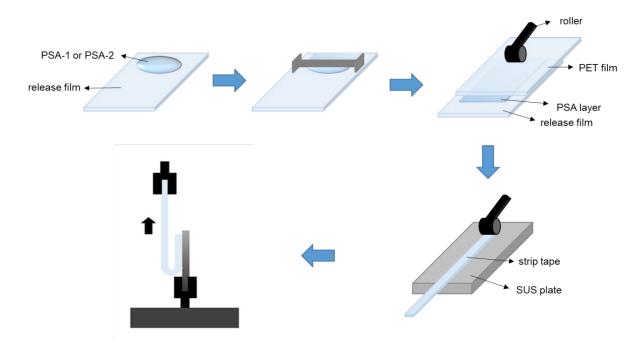


Figure S2. The schematic for the peel strength test.

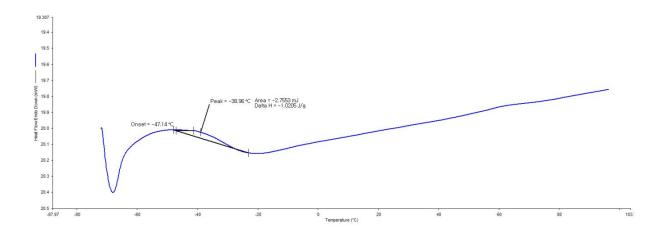


Figure S3. A DSC graph of polymer **1** obtained by increasing the temperature from -70 to 100 °C.

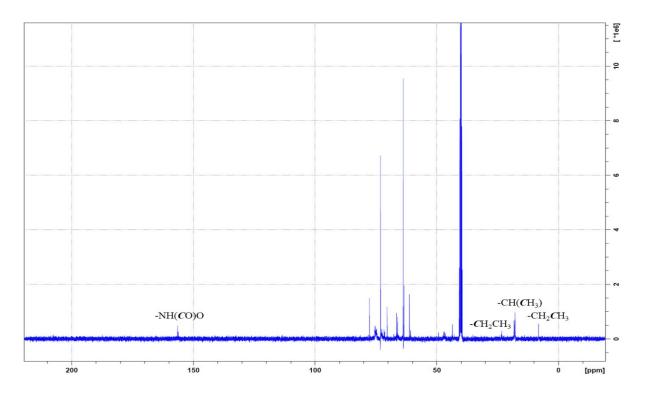


Figure S4. A ${}^{13}\text{C-NMR}$ spectrum of oligomer MA-1 in DMSO- d_6 .

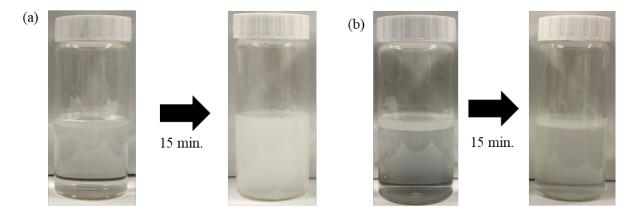


Figure S5. Toluene/water bilayers (a) with and (b) without oligomer MA-1 15 min after mixing.

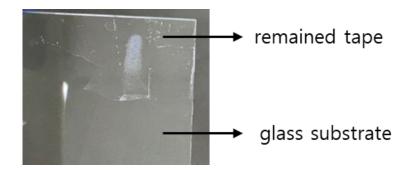


Figure S6. Remainders after detachment of the PSA-0 tape from a glass substrate.

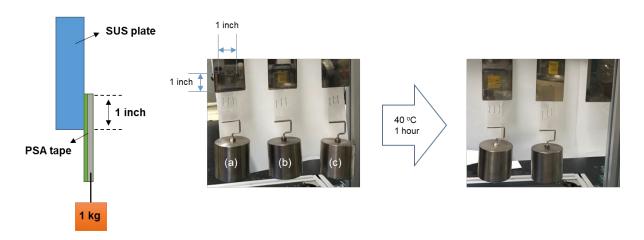


Figure S7. The shear resistance test of (a) PSA-**0**, (b) PSA-**1** and (c) PSA-**2** tapes. The weight with 1 kg was hung to the PSA tapes adhered to a SUS plate in a dimension of 1 inch by 1 inch, which kept in 40 °C for 1 h. While the time to shear failure for the PSA-**0** and PSA-**1** tapes exceeded 1 h (t > 1 h), that for the PSA-**2** tape was 15 min (t = 15 min).

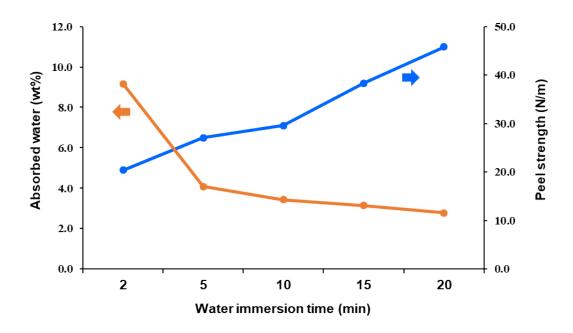


Figure S8. The weight percentage of the absorbed water in wr-PSA and the peel strength of wr-PSA over water immersion time at 25 °C.

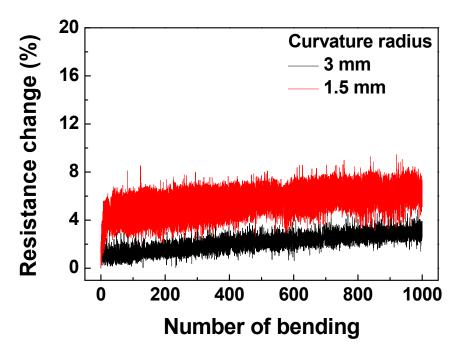


Figure S9. Resistance change of the AgNWs/1.4-μm-thick PET electrode with the bending numbers employing bending radii of 1.5 and 3 mm.

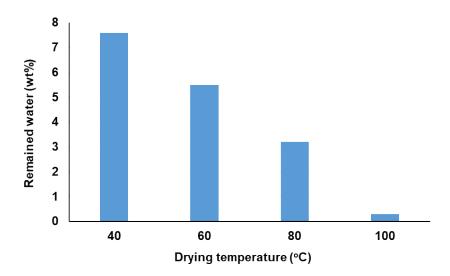


Figure S10. The weight percentage of the remained water in PSA-1 after drying at 40 °C, 60 °C, 80 °C and 100 °C.

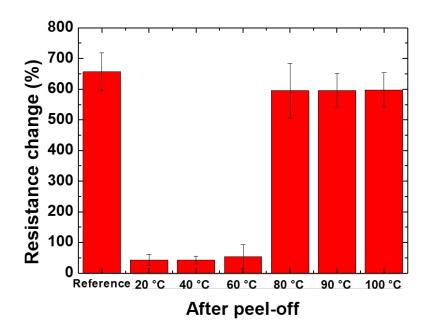


Figure S11. Resistance change of the water-treated AgNWs/1.4-μm-thick PET electrodes upon peeling-off after maintaining at various temperatures for 20 min. The reference refers to samples that did not experience water treatment and drying at high temperatures.